

# EE 362 Electronic, Magnetic, & Optical Properties of Materials

## 3-0 (3 credit hours)

**Bring-** pen/pencil(s), equation sheet(s)/allowed materials, calculator, and straight-edge/ruler.

**Text:** Semiconductor Physics and Devices: Basic Principles (4<sup>th</sup> Edition), Donald A. Neamen, McGraw Hill, 2012, ISBN 978-0-07-352958-5.

### **Chapter 1 The Crystal Structure of Solids**

- Space lattices/crystal structures
- Bravais lattices
- Atomic volume & surface density
- Miller indices

### **Chapter 2 Introduction to Quantum Mechanics**

- Photoelectric effect
- K.E., photon energy, work function
- eV versus Joules
- deBroglie wavelength and photon momentum
- Uncertainty Principle
- Schrodinger's Wave Equation
- Probability density function and potential barriers &/or wells
- Transmission & reflection coefficients

### **Chapter 3 Introduction to the Quantum Theory of Solids**

- Quantized energy levels & energy bands
- Kronig-Penney Model and  $k$ -space diagram
- Conduction and valence bands
- Drift current density
- Electron effective mass
- Holes and hole effective mass
- Density of States Function
- Fermi-Dirac probability function and Maxwell-Boltzmann approximation

### **Chapter 4 The Semiconductor in Equilibrium**

- Electron  $n_0$  & hole  $p_0$  concentrations in conduction & valence bands
- Intrinsic carrier concentration  $n_i = p_i$
- Intrinsic Fermi energy level  $E_{Fi}$  in relation to  $E_c$ ,  $E_v$ , and  $E_{\text{midgap}}$
- Dopants & ionization energy
- Fermi energy level  $E_F$  for doped/extrinsic semiconductors versus  $E_{Fi}$
- $n_0 p_0 = n_i^2$  product

- Ionization rate versus temperature
- Equilibrium electron and hole concentrations for doped/extrinsic semiconductors

### **Chapter 5 Carrier Transport Phenomena**

- Drift current density
- Diffusion current density
- Carrier mobility  $\mu$  and diffusion coefficient  $D$
- Conductivity  $\sigma$  and resistivity  $\rho$  and resistance  $R$
- Drift velocity  $v_d$
- Einstein Relation relating mobility and diffusion coefficient
- Hall Effect

### **Chapter 6 Nonequilibrium Excess Carriers in Semiconductors**

- Excess Carriers
- Recombination and generation
- Excess minority carrier lifetime
- Time-dependent diffusion equations
- Ambipolar Transport equations
- Ambipolar diffusion coefficient and mobility
- Diffusion length
- Quasi-Fermi energy levels

### **Chapter 7 The pn Junction**

- Built-in potential barrier  $V_{bi}$
- Thermal voltage  $V_t$
- Depletion layer/space charge widths & maximum electric field at zero bias
- Depletion layer/space charge widths & maximum electric field w/ reverse bias
- Junction capacitance  $C'$  (F/m<sup>2</sup>) and  $C$  (F)
- One-sided pn junctions

### **Chapter 8 The pn Junction Diode**

- Be able to find majority and minority carrier concentrations on each side of depletion layer
- Be able to find minority carrier concentrations in p- and n-regions using ambipolar transport eq'n
- Be able to find electron  $J_n$ , hole  $J_p$ , & total  $J_{tot}$  current densities across depletion layer
- Be able to find ideal reverse saturation current density  $J_s$  across depletion layer
- Be able to find majority carrier current densities in p- and n-regions
- Small-signal diffusion conductance  $g_d$ , resistance  $r_d$ , and capacitance  $C_d$  as well as admittance  $Y$
- Add in junction capacitance and series resistance for p- and n-regions to get complete small-signal circuit model of pn diode.

**Chapter 10 Fundamentals of the Metal-Oxide-Semiconductor Field-effect-Transistor**

- MOS capacitor depletion layer thickness  $x_d$
- Potential associated with energy differences between  $E_F$  and  $E_{Fi}$ ,  $\phi_{fp}$  and  $\phi_{fn}$ .
- Threshold potential  $\phi_s$  and maximum depletion layer thickness  $x_{dT}$
- Surface charge density at threshold and beyond
- Metal-semiconductor work function  $\phi_{ms}$ , equivalent trapped charge surface density  $Q_{ss}'$ , oxide capacitance  $C_{ox}$ , and flat band voltage  $V_{FB}$
- Charge density in depletion layer at threshold  $|Q_{SD}'(\max)|$  and threshold (gate) voltage  $V_T$
- $C$ - $V$  characteristics (e.g.,  $C'$ (acc),  $C'$ (depl),  $C'_{FB}$ ,  $C'_{min}$ , &  $C'$ (inv)) for MOS capacitors
- n- & p-channel MOSFET saturation voltage  $V_{DS}(\text{sat})$
- n- & p-channel MOSFET drain current  $I_D$  equations for linear and saturation regions
- Transconductance for linear  $g_m$  and saturation  $g_{ms}$  regions
- MOSFET substrate bias effects- change in  $V_T$  and  $Q_{SD}'$  and body effect coefficient  $\gamma$
- MOSFET frequency limits

**Chapter 12 The Bipolar Transistor**

- Modes- active, saturation, cutoff, and inverse
- Minority carrier concentration distributions for forward-active (linear) mode
- Common-base current gain  $\alpha$
- Emitter injection efficient factor  $\gamma$ , base transport factor  $\alpha_T$ , and recombination factor  $\delta$
- Emitter current densities and currents-  $J_{nE}$ ,  $J_{pE}$ ,  $I_{nE}$ ,  $I_{pE}$ ,  $J_E$ , and  $I_E$
- Common-emitter current gain  $\beta$
- $I_C$  and  $I_B$